

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S1	100	("6091120" "6664196" "6156126" "6174766" "6177334" "5407839" "6283835" "6727187" "6730239" "6080677" "6245650" "6544873" "6642585" "5989353" "6074960" "5422308" "6034419" "6043005" "6174816" "5654570" "5897349" "6221766" "6221766" "6184083" "5428244" "4419183" "6326342" "6465403" "6057212" "6143618" "5940735" "6166428" "5585302" "6060766" "6071784" "6300664" "6323115" "6387827" "6436783" "6603181" "6770500" "6784038" "6803266" "4525240" "4522683" "5803956" "4554049" "5651917" "6036835" "4356069").pn.	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/24 10:49
S2	23899	hydrogen peroxide and sulfuric acid	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2004/12/21 13:49
S3	29	S1 and S2	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2004/12/21 13:50
S4	18	S1 and S2 and tungsten	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2004/12/21 15:17
S5	14245	tungsten and cleaning	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2004/12/21 15:18
S6	1333	tungsten and cleaning and gate electrode	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2004/12/21 15:19
S7	235	tungsten and cleaning and gate electrode and hydrogen peroxide	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2004/12/21 15:20
S8	128	tungsten and cleaning and gate electrode and hydrogen peroxide and sulfuric acid	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2004/12/21 15:21
S9	111	tungsten and cleaning and gate electrode and hydrogen peroxide same sulfuric acid	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2004/12/21 16:18

S10	14	tungsten same cleaning and gate electrode and hydrogen peroxide same sulfuric acid	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/09/15 14:01
S11	27	tungsten same clean\$7 and gate electrode and hydrogen peroxide same sulfuric acid	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2004/12/21 18:25
S12	1252	clean\$7 same hydrogen peroxide same sulfuric acid	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2004/12/21 18:26
S13	238	clean\$7 same hydrogen peroxide same sulfuric acid and tungsten	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2004/12/21 18:28
S14	92	clean\$7 same hydrogen peroxide same sulfuric acid and tungsten and gate electrode	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2004/12/21 18:29
S15	7993	nitride same growth and semiconductor	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/21 20:25
S16	3398	nitride same growth and semiconductor and epitaxial	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/21 20:25
S17	1070973	nitride same growth and semiconductor and epitaxial and CMurray III, Clarence "[Clarence. Murray@cfsan.fda.gov]D"	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/15 14:06
S18	1312	nitride same growth and semiconductor and epitaxial and Cvd	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/21 20:27
S19	22851	nitride same Cvd	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/21 20:27
S20	22851	nitride same Cvd	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/21 20:28
S21	573	nitride and ald	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2004/12/21 20:29

S22	53	sulfuric acid and hydrogen peroxide	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2004/12/22 19:33
S23	1	sulfuric acid and hydrogen peroxide same cleaning	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2004/12/22 19:34
S24	3	sulfuric acid and hydrogen peroxide same clean\$4	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2004/12/22 19:34
S25	1	2002-178025.NRAN.	DERWENT	OR	OFF	2004/12/22 19:44
S26	15	("4242698" "4917759" "5173152" "5626681" "5677237" "5855811" "5904560" "5930613" "5946595" "5972123" "6017809" "6107165" "6149828" "6156629" "6178972").PN.	US-PGPUB; USPAT; USOCR	OR	OFF	2004/12/22 19:55
S27	1	("6664196").URPN.	USPAT	OR	OFF	2004/12/22 19:57
S28	25323	tungsten and clean\$4	USPAT	OR	ON	2004/12/22 19:58
S29	2222	tungsten and clean\$4 and gate adj electrode	USPAT	OR	ON	2004/12/22 19:58
S30	225	tungsten and clean\$4 and gate adj electrode and sulfuric adj acid	USPAT	OR	ON	2004/12/22 20:04
S31	664	tungsten and clean\$4 same sulfuric adj acid	USPAT	OR	ON	2004/12/22 20:04
S32	116438	tungsten and clean\$4 same sulfuric adj acid same hydrogen peroxide	USPAT	OR	ON	2004/12/22 20:04
S33	234	tungsten and clean\$4 same sulfuric adj acid same hydrogen adj peroxide	USPAT	OR	ON	2004/12/22 20:05
S34	25	tungsten same clean\$4 same sulfuric adj acid same hydrogen adj peroxide	USPAT	OR	ON	2004/12/22 20:13
S35	1	tungsten same piranha adj clean\$4	USPAT	OR	ON	2005/09/15 14:06
S36	11	sulfuric acid same hydrogen peroxide same clean\$4 and "6:1"	USPAT	ADJ	ON	2004/12/22 20:22
S37	12	tungsten near5 gate and piranha	USPAT	ADJ	ON	2004/12/22 20:22
S38	6	Clean chemistry and tungsten	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/01/11 17:13

S39	3	Clean chemistry and sulfuric acid	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/01/11 17:16
S40	100	("6091120" "6664196" "6156126" "6174766" "6177334" "5407839" "6283835" "6727187" "6730239" "6080677" "6245650" "6544873" "6642585" "5989353" "6074960" "5422308" "6034419" "6043005" "6174816" "5654570" "5897349" "6221766" "6221766" "6184083" "5428244" "4419183" "6326342" "6465403" "6057212" "6143618" "5940735" "6166428" "5585302" "6060766" "6071784" "6300664" "6323115" "6387827" "6436783" "6603181" "6770500" "6784038" "6803266" "4525240" "4522683" "5803956" "4554049" "5651917" "6036835" "4356069").pn.	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/24 10:53
S41	26	S40 and sulfuric acid	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	OFF	2005/01/24 10:58
S42	34	S40 and sulfuric acid	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/01/24 17:05
S43	15722	sulphuric acid and cleaning	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/01/25 10:37
S44	3596	sulphuric acid and cleaning and hydrogen peroxide	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/01/25 12:11
S45	3590	sulphuric acid and cleaning and hydrogen peroxide	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/01/25 12:11
S46	554	sulphuric acid and cleaning and hydrogen peroxide and tungsten	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/01/25 12:12
S47	351	sulphuric acid same hydrogen peroxide and tungsten and cleaning	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/01/25 15:03
S48	1	2002-178025.NRAN.	DERWENT	OR	OFF	2005/01/25 14:20

S49	0	("2002-178025").PN.	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/01/25 14:31
S50	260	sulphuric acid same hydrogen peroxide and tungsten and cleaning and minute	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/01/25 15:05
S51	89	sulphuric acid same hydrogen peroxide same minute and tungsten and cleaning	USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/01/25 15:05
S52	1	2002-178025.NRAN.	DERWENT	OR	OFF	2005/07/07 14:51
S53	361	438/704.ccls.	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/15 13:36
S54	947	438/745.ccls.	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/15 13:35
S55	167	438/748.ccls.	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/15 13:42
S56	416	438/704.ccls.	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/15 13:36
S57	122	438/749.ccls.	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/15 13:48
S58	936	438/585.ccls.	USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	OFF	2005/09/15 13:57
S59	332	438/585.ccls.	US-PGPUB	OR	OFF	2005/09/15 14:11
S60	28	tungsten same cleaning and gate electrode and hydrogen peroxide same sulfuric acid	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	ADJ	ON	2005/09/15 14:02
S61	2	tungsten same piranha adj clean\$4	US-PGPUB; USPAT; EPO; JPO; DERWENT; IBM_TDB	OR	ON	2005/09/15 14:07
S62	55	438/704.ccls.	US-PGPUB	OR	OFF	2005/09/15 14:15

S63	213	438/745.ccls.	US-PGPUB	OR	OFF	2005/09/15 14:15
S64	15	438/748.ccls.	US-PGPUB	OR	OFF	2005/09/15 14:15
S65	10	438/749.ccls.	US-PGPUB	OR	OFF	2005/09/15 14:15